

	Type	L #	Hits	Search Text	DBs	Time Stamp	Comments	Error Definition	Errors
1	BRS	L1	21	duv with \$5resist and \$5lithography and low adj k adj dielectric and (silicon adj oxycarbide or sioc)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/19 01:09			
2	BRS	L2	18	("5300460" "5530581" "5661093" "5804259" "5926740" "6054379" "6159871" "6284149" "6303523").PN. OR ("6372661").URPN.	US-PGPUB; USPAT; USOCR	2005/09/19 01:06			
3	BRS	L3	5	duv with \$5resist and \$5lithography and low adj k adj dielectric and (silicon adj oxycarbide or sioc) with (ar\$2 or anti adj reflect\$4)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/19 01:11			
4	BRS	L4	7	duv with \$5resist and low adj k adj dielectric and (silicon adj oxycarbide or sioc) with (ar\$2 or anti adj reflect\$4)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/19 02:06			

	Type	L #	Hits	Search Text	DBs	Time Stamp	Co mm en ts	Er ro r De fi ni ti on	Er ro rs
5	BRS	L5	0	duv and low adj k adj dielectric and (silicon adj oxycarbide or sioc) with (ar\$2 or anti adj reflect\$4) with (hydrogen or h2) with (treat\$5 or plasma)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/19 02:10			
6	BRS	L6	0	duv and dielectric and (silicon adj oxycarbide or sioc) with (ar\$2 or anti adj reflect\$4) with (hydrogen or h2) with (treat\$5 or plasma)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/19 02:11			
7	BRS	L7	0	(silicon adj oxycarbide or sioc) with (ar\$2 or anti adj reflect\$4) with (hydrogen or h2) with (treat\$5 or plasma)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/19 02:09			
8	BRS	L8	10	(silicon adj oxycarbide or sioc) with (ar\$2 or anti adj reflect\$4) with (hydrogen or h2)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/19 02:09			

	Type	L #	Hits	Search Text	DBs	Time Stamp	Co mm en ts	Er ro r De fi ni ti on	Er ro rs
9	BRS	L9	4	duv and low adj k adj dielectric and (silicon adj oxycarbide or sioc) with (ar\$2 or anti adj reflect\$4) with (hydrogen or h2)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/19 02:11			
10	BRS	L10	4	duv and (silicon adj oxycarbide or sioc) with (ar\$2 or anti adj reflect\$4) with (hydrogen or h2)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/19 02:11			
11	BRS	L11	2	duv and dielectric and (silicon adj oxycarbide or sioc) with (hydrogen or h2) with (treat\$5 or plasma)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/19 02:12			
12	BRS	L12	12	duv and dielectric and (silicon adj oxycarbide or sioc) with (hydrogen or h2)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/19 02:41			
13	BRS	L13	2	(duv and (silicon adj oxycarbide or sioc) with (hydrogen or h2)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/19 02:41			

	Type	L #	Hits	Search Text	DBs	Time Stamp	Co mm en ts	Er ro r De fi ni ti on	Er ro rs
14	BRS	L14	0	(438/597).ccls. and duv and (silicon adj oxycarbide or sioc) with (hydrogen or h2)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/19 02:42			
15	BRS	L15	3	(438/637).ccls. and duv and (silicon adj oxycarbide or sioc) with (hydrogen or h2)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/19 02:43			
16	BRS	L16	1	(438/636).ccls. and duv and (silicon adj oxycarbide or sioc) with (hydrogen or h2)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/19 02:43			
17	BRS	L17	3	(438/780).ccls. and duv and (silicon adj oxycarbide or sioc) with (hydrogen or h2)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/19 02:44			
18	BRS	L18	1	(438/952).ccls. and duv and (silicon adj oxycarbide or sioc) with (hydrogen or h2)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/19 02:44			
19	BRS	L19	9	("438"/\$).ccls. and duv and (silicon adj oxycarbide or sioc) with (hydrogen or h2)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/19 02:45			

	Type	L #	Hits	Search Text	DBs	Time Stamp	Comments	Error Definition	Errors
20	BRS	L20	35	("438"/\$).cccls. and \$2uv and (silicon adj oxycarbide or sioc) with (hydrogen or h2)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2005/09/19 02:45			